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			Docket No.
CERTIFICATE OF TRANSMISSION BY FACSIMILE (37 CFR 1.8) Applicant(s): Ellis-Monaghan et al.			BUR920040160US1
Application No.	Filing Date 9/21/2004	Examiner Forde, Remmon R.	Group Art Unit 2826
Invention: HALO IMPLAN	NT IN SEMICONDUCTOR S	TRUCTURES	
•			
) hereby certify that this		Restriction Election (2 pages)	
	ed to the United States Pater	(Identify type of correspondence) nt and Trademark Office (Fax. No	o. 703-872 - 9306
on 2/11/2005			
(Date)	.,,		
		Kim Dwiles (Typed or Printed/Name of Person	ki Signing Certificate),
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Docket No.BUR920040160US1

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Ellis Monaghan et al.

Group Art Unit: 2826

Filed: 9/21/2004

Examiner: Forde, Remmon R.

Scrial No.: 10/711,484

Title: HALO IMPLANT IN SEMICONDUCTOR STRUCTURES

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

RESTRICTION ELECTION

In response to the Restriction Requirement dated January 27, 2005, Applicants hereby provisionally elect Group I, claims 1-14, drawn to a method of making a semiconductor device, classified in class 438, subclass 217. This election is made with traverse, and Applicants hereby reserve the right to file a divisional application in connection with uncleeted claims 15-20, drawn to a semiconductor device.

With regard to the Restriction Requirement, Applicants respectfully submit that the subject matter of all claims 1-20 is sufficiently related that a thorough search for the subject matter of any one group of claims would encompass a search for the subject matter of the remaining claims. Thus, Applicants respectfully submit that the search and the examination of the entire application could be made without serious burden. See MPEP § 803, in which it is stated

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that "if the search and examination of the entire application can be made without serious burden, the Examiner must examine it on the merits." Applicants respectfully submit that this policy should apply in the present application in order to avoid unnecessary delay and expense to Applicants and duplicative examination by the Patent Office.

Should the Examiner require or request anything further from Applicants prior to examination, the Examiner is requested to contact Applicants' undersigned representative at the telephone number below. Otherwise, Applicants request early and favorable examination on the merits.

Date:

Khoi D. Nguyen

Registration No. 47,820

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